



2822

PATENT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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A. [signature]

Signature

Applicant : Jerome T. Chu, et al.  
Application No. : 09/964,227  
Filed : September 26, 2001  
Title : METHOD AND STRUCTURE FOR MODULAR, HIGHLY  
LINEAR MOS CAPACITORS USING NITROGEN  
IMPLANTATION  
Grp./Div. : 2822  
Examiner : M. Lewis  
Docket No. : 42022/MJM/A717

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## RESPONSE TO RESTRICTION REQUIREMENT

Assistant Commissioner for Patents  
Washington, D.C. 20231

Post Office Box 7068  
Pasadena, CA 91109-7068  
September 25, 2002

Commissioner:

In response to the Office action (Restriction Requirement) dated August 27, 2002, applicants acknowledge the Examiner's requirement of restriction in the above-identified application and hereby elect Group II claims (claims 1-19) drawn to the method of forming MOS structure, classified in class 438, subclass 190, for the purposes of further prosecuting this patent application. This election is made without traverse.

In view of such election, applicants respectfully request that claims 1-19 be examined on the merits.

Respectfully submitted,  
CHRISTIE, PARKER & HALE, LLP

By

Mark J. Marcelli  
Reg. No. 36,593  
626/795-9900

MJM/dlf

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